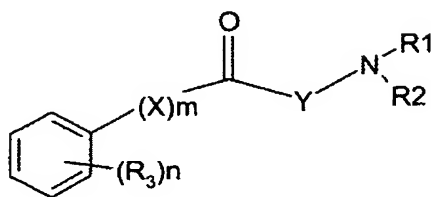


AMENDMENTS TO THE CLAIMS

1. (Original): A process comprising topically applying to wrinkled skin a composition comprising, in a physiologically acceptable medium, at least one compound of formula (I):



(I)

in which:

R_1 denotes a hydrogen atom or a linear or branched, saturated or unsaturated C_1 - C_8 alkyl group,

R_2 denotes:

- a linear, branched or cyclic, saturated or unsaturated C_1 - C_{20} alkyl group, optionally substituted with an $=O$ group, and/or with one or more of $-CN$, $-OR$, $-SR$, $-NRR'$, $-COR$, $-COOR$, $-CONRR'$, $-NR-CO-R'$, $-NR-CO-NR'R''$ or $-CF_3$ groups and/or with one or more halogen atoms and/or with a phenyl group optionally substituted with a C_1 - C_4 alkyl group, a C_1 - C_4 alkoxy group, a hydroxyl group, a halogen atom and/or a CF_3 group,
- an aryl group optionally substituted with at least one of a C_1 - C_4 alkyl group, a C_1 - C_4 alkoxy group, a hydroxyl group, a halogen atom or a CF_3 group, or
- a heterocycle,

in which R, R' and R'' independently denote a hydrogen atom or a linear or branched C₁-C₄ alkyl group, or an aryl group,

R₃ denotes a linear, branched or cyclic, saturated or unsaturated C₁-C₁₂ alkyl group, or an aryl group, optionally substituted with a hydroxyl group, a C₁-C₄ alkoxy group or a hydrogen atom, a -CN, -OR, -SR, -NRR', -COR, -COOR, -CONRR', -NR-CO-R', -NR-CO-NR'R'' or -CF₃ group or a halogen atom,

in which R, R' and R'' have the meaning given above,

X is a saturated or unsaturated, optionally substituted linear C₁-C₉ alkylene group,

Y is a saturated or unsaturated, optionally substituted linear C₁-C₁₀ alkylene group,

the substituents of X and Y being chosen independently from -OR, -SR, -NRR', -COR, -COOR, -CO-NRR', -NR-CO-R'R'', CF₃ groups and mixtures thereof,

in which R, R' and R'' have the meaning given above,

m is 0 or 1,

n is 0, 1, 2 or 3,

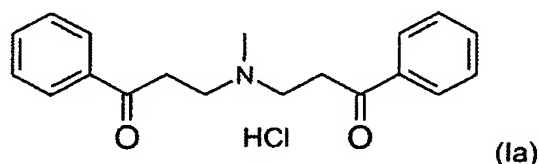
and the addition salts thereof with an acid.

2. (Original): The process according to Claim 1, wherein said composition comprises an addition salt of a compound of formula (I) obtained by addition with a mineral acid selected from the group consisting of hydrochloric acid, sulphuric acid, nitric acid and phosphoric acid.

3. (Withdrawn): The process according to Claim 1, wherein said composition comprises an addition salt of a compound of formula (I) obtained by addition with an organic

acid elected from the group consisting of succinic acid, fumaric acid, lactic acid, glycolic acid, citric acid and tartaric acid.

4. (Original): The process according to Claim 1, wherein $m = 0$.
5. (Original): The process according to Claim 1, wherein $n = 0$.
6. (Original): The process according to Claim 1, wherein Y is a linear C_1 - C_3 alkylene group.
7. (Original): The process according to Claim 1, wherein R_1 is a C_1 - C_3 alkyl group.
8. (Original): The process according to Claim 1, wherein R_2 is a C_1 - C_3 alkyl group substituted with an arylcarbonyl group.
9. (Original): The process according to Claim 1, wherein said composition comprises the following compound of Formula (Ia):



10. (Original): The process according to Claim 1, wherein the compound of formula (I) represents from 0.1% to 2% of the total weight of the composition.
11. (Original): The process according to Claim 1, wherein said composition further comprises at least one compound selected from the group consisting of desquamating agents; moisturizers; depigmenting agents; propigmenting agents; antiglycation agents; NO-synthase inhibitors; agents for stimulating the synthesis of dermal or epidermal macromolecules and/or for preventing their degradation; agents for stimulating the proliferation of fibroblasts and/or

keratinocytes or for stimulating the differentiation of keratinocytes; dermo-decontracting agents; tensioning agents; antipollution agents and/or free-radical scavengers; agents acting on the capillary circulation; agents acting on the energy metabolism of cells; and mixtures thereof.

12. (Original): The process according to Claim 1, wherein said composition is applied to the areas of the face or forehead marked with expression wrinkles and fine lines.

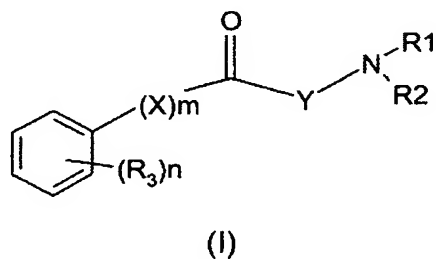
13. (Currently Amended): The process according to Claim 1, ~~wehreim~~ wherein said composition is applied to wrinkles and fine lines lying radially around the mouth and/or the eyes and/or horizontally on the forehead and/or lying between the eyebrows.

14. (Original): The process according to Claim 1, wherein said process smoothes out wrinkles and fine lines.

15. (Original): The process according to Claim 14, wherein said wrinkles and fine lines are expression wrinkles and fine lines.

16-23. (Canceled).

24. (New): A method of treating wrinkles on skin in need thereof comprising applying to the skin a wrinkle treating effective amount of at least one compound of formula (I):



in which:

R₁ denotes a hydrogen atom or a linear or branched, saturated or unsaturated C₁-C₈ alkyl group,

R₂ denotes:

- a linear, branched or cyclic, saturated or unsaturated C₁-C₂₀ alkyl group, optionally substituted with an =O group, and/or with one or more of -CN, -OR, -SR, -NRR', -COR, -COOR, -CONRR', -NR-CO-R', -NR-CO-NR'R'' or -CF₃ groups and/or with one or more halogen atoms and/or with a phenyl group optionally substituted with a C₁-C₄ alkyl group, a C₁-C₄ alkoxy group, a hydroxyl group, a halogen atom and/or a CF₃ group,
 - an aryl group optionally substituted with at least one of a C₁-C₄ alkyl group, a C₁-C₄ alkoxy group, a hydroxyl group, a halogen atom or a CF₃ group, or
 - a heterocycle,
- in which R, R' and R'' independently denote a hydrogen atom or a linear or branched C₁-C₄ alkyl group, or an aryl group,

R₃ denotes a linear, branched or cyclic, saturated or unsaturated C₁-C₁₂ alkyl group, or an aryl group, optionally substituted with a hydroxyl group, a C₁-C₄ alkoxy group or a hydrogen atom, a -CN, -OR, -SR, -NRR', -COR, -COOR, -CONRR', -NR-CO-R', -NR-CO-NR'R'' or -CF₃ group or a halogen atom,

in which R, R' and R'' have the meaning given above,

X is a saturated or unsaturated, optionally substituted linear C₁-C₉ alkylene group,

Y is a saturated or unsaturated, optionally substituted linear C₁-C₁₀ alkylene group,

the substituents of X and Y being chosen independently from -OR, -SR, -NRR', -COR, -COOR, -CO-NRR', -NR-CO-R'R'', CF₃ groups and mixtures thereof,

in which R, R' and R'' have the meaning given above,

m is 0 or 1,

n is 0, 1, 2 or 3,

and the addition salts thereof with an acid.

25. (New): The method according to Claim 24, wherein the compound of formula (I) is present in a composition and represents from 0.01% to 10% of the total weight of the composition.

26. (New): The method according to Claim 24, wherein the compound of formula (I) is present in a composition and represents from 0.05% to 5% of the total weight of the composition.

27. (New): The method according to Claim 24, wherein the compound of formula (I) is present in a composition and represents from 0.1% to 2% of the total weight of the composition.

28. (New): The process according to Claim 1, wherein the compound of formula (I) represents from 0.01% to 10% of the total weight of the composition.

29. (New): The process according to Claim 1, wherein the compound of formula (I) represents from 0.05% to 5% of the total weight of the composition.